1. Record Nr. UNINA9910830033303321 Autore Ashburn Peter **Titolo** SiGe heterojunction bipolar transistors [[electronic resource] /] / Peter Ashburn Hoboken, NJ,: John Wiley & Sons, c2003 Pubbl/distr/stampa **ISBN** 1-280-26903-0 9786610269037 0-470-09073-1 0-470-09074-X Descrizione fisica 1 online resource (288 p.) Disciplina 621.313 621.3815282 Soggetti Bipolar transistors Silicon Germanium Lingua di pubblicazione Inglese **Formato** Materiale a stampa Livello bibliografico Monografia Note generali Description based upon print version of record. Nota di bibliografia Includes bibliographical references and index. Nota di contenuto SiGe Heterojunction Bipolar Transistors; Contents; Preface; Physical Constants and Properties of Silicon and Silicon-Germanium; List of Symbols; 1 Introduction; 1.1 Evolution of Silicon Bipolar Technology; 1.2 Evolution of Silicon-Germanium HBT Technology; 1.3 Operating Principles of the Bipolar Transistor; References; 2 Basic Bipolar Transistor Theory; 2.1 Introduction; 2.2 Components of Base Current; 2.3 Fundamental Equations; 2.3.1 Assumptions; 2.4 Base Current; 2.4.1 Base Current in Shallow Emitters; 2.4.2 Base Current in Deep Emitters; 2.4.3 Recombination Current in the Neutral Base 2.5 Collector Current2.6 Current Gain; 2.7 Gummel Numbers; 3 Heavy Doping Effects; 3.1 Introduction; 3.2 Majority and Minority Carrier Mobility; 3.3 Bandgap Narrowing; 3.4 Minority Carrier Lifetime; 3.5 Gain and Heavy Doping Effects; 3.6 Non-uniform Doping Profiles; References: 4 Second-Order Effects: 4.1 Introduction: 4.2 Low Current Gain; 4.2.1 Recombination via Deep Levels; 4.2.2 Recombination

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Sommario/riassunto

SiGe HBTs is a hot topic within the microelectronics community because of its applications potential within integrated circuits operating at radio frequencies. Applications range from high speed optical networking to wireless communication devices. The addition of germanium to silicon technologies to form silicon germanium (SiGe) devices has created a revolution in the semiconductor industry. These transistors form the enabling devices in a wide range of products for wireless and wired communications. This book features:SiGe products include chip sets for wireless cellular handsets